

Stéphane Sebban

Julien Gautier

David Ros

Philippe Zeitoun *Editors*

# X-Ray Lasers 2012

Proceedings of the 13th International  
Conference on X-Ray Lasers, 11–15 June  
2012, Paris, France

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Philippe Zeitoun

Editors

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*Editors*

Stéphane Sebban  
Laboratoire d'Optique Appliquée  
ENSTA  
Palaiseau, France

David Ros  
LPGP  
Université Paris-Sud  
Orsay, France

Julien Gautier  
Laboratoire d'Optique Appliquée  
ENSTA  
Palaiseau, France

Philippe Zeitoun  
Laboratoire d'Optique Appliquée  
ENSTA  
Palaiseau, France

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# Preface

These proceedings comprise invited and contributed papers presented at the 13th International Conference on X-Ray Lasers (ICXRL 2012) which was held 11–15 June 2012 in Paris, in the famous Quartier Latin, inside the historical Center of Cordeliers. This conference is part of a continuing series dedicated to recent developments and applications of x-ray lasers and other coherent x-ray sources with attention to supporting technologies and instrumentation.

New results in the generation of intense, coherent x-rays and progress towards practical devices and their applications are reported in these proceedings, including areas of research in plasma-based x-ray lasers, 4th generation accelerator-based sources and higher harmonic generation.

Recent achievements related to the increase of the repetition rate up to 100 Hz and shorter wavelength collisional plasma-based soft x-ray lasers down to about 7 nm are presented. Seeding the amplifying plasma with a femtosecond high-order harmonic of infrared laser was foreseen as the required breakthrough to break the picosecond frontier. Numerical simulations based on the Maxwell-Bloch model are presented in these proceedings, transposing the chirped pulse amplification technique to the x-ray domain in order to increase the time over which the femtosecond seed can be amplified.

These proceedings also include innovative applications of soft x-ray lasers based on techniques and diagnostics relevant to topical domains such as EUV lithography, inertial confinement fusion, or warm dense matter physics.

We would like to thank the International Advisory Board for helping to organize the scientific program and the Local Organizing Committee for operation of the meeting. Also we would like to thank the Conference Secretary and the supporting staff for running the conference smoothly and editing these conference proceedings.

Paris, France

Stéphane Sebban  
Julien Gautier  
David Ros  
Philippe Zeitoun

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# Contributors

**O. Acef** SYRTE, Observatoire de Paris, UPMC, CNRS, LNE, Paris, France

**D. Alessi** National Science Foundation ERC for Extreme Ultraviolet Science and Technology, Fort Collins, USA; Department of Electrical and Computer Engineering, Colorado State University, Fort Collins, CO, USA

**E. Allaria** Elettra-Sincrotrone Trieste, Basovizza, Trieste, Italy

**H.H. An** Shanghai Institute of Laser Plasma, Shanghai, China

**E.H. Anderson** NSF ERC for Extreme Ultraviolet Science and Technology, Department of Electrical & Computer Engineering, Colorado State University, Fort Collins, CO, USA; NSF ERC for Extreme Ultraviolet Science and Technology and Center for X-ray Optics, LBNL, Berkeley, CA, USA

**A.V. Andreev** Physics Department, M.V. Lomonosov Moscow State University, Moscow, Russia

**I.A. Andriyash** Univ. Bordeaux, CNRS, CEA, CELIA (Centre Lasers Intenses et Applications), Talence, France

**I.A. Artyukov** P.N. Lebedev Physical Institute, Moscow, Russia

**B. Aurand** Johannes-Gutenberg Universität Mainz, Mainz, Germany; ExtreMe Matter Institute EMMI, Darmstadt, Germany; GSI Helmholtzzentrum fuer Schwerionenforschung, Darmstadt, Germany

**M. Baba** Institute of Solid State Physics, The University of Tokyo, Kashiwa, Chiba, Japan

**V. Bagnoud** Helmholtz Institute Jena, Jena, Germany; GSI Helmholtz Center for Heavy-Ion Research, Darmstadt, Germany

**G. Balakrishnan** Department of Electrical Engineering, University of New Mexico and Center for High Technology Materials, Albuquerque, NM, USA

**E. Balaur** Department of Physics, La Trobe University, Melbourne, Australia; Australian Research Council Centre of Excellence for Coherent X-Ray Science, Melbourne, Australia

**P. Balcou** Univ. Bordeaux, CNRS, CEA, CELIA (Centre Lasers Intenses et Applications), Talence, France

**J.E. Balmer** Institute of Applied Physics, University of Bern, Bern, Switzerland

**A. Baranowska-Korczyk** Institute of Physics, Polish Academy of Sciences, Warsaw, Poland

**P. Barroso** GEPI, Observatoire de Paris, Univ. Paris-Diderot, CNRS, Paris, France

**A. Bartnik** Institute of Optoelectronics, Military University of Technology, Warsaw, Poland

**C. Benabderrahmane** Synchrotron SOLEIL, Saint-Aubin, France

**D. Benredjem** LAC, CNRS-Université Paris-Sud, Orsay, France

**M. Berrill** NSF-ERC for EUV Science and Technology, Colorado State University, Fort Collins, USA; National Science Foundation ERC for Extreme Ultraviolet Science and Technology, Fort Collins, USA; Department of Electrical and Computer Engineering, Colorado State University, Fort Collins, CO, USA; Oak Ridge National Laboratory, Oak Ridge, TN, USA

**P. Betinelli** Synchrotron SOLEIL, Saint-Aubin, France

**S. Bielawski** PhLAM/CERLA, Lille, France

**D. Bleiner** Institute of Applied Physics, University of Bern, Bern, Switzerland

**K. Bohacek** Institute of Physics of ASCR, Prague, Czech Republic

**A. Boudaa** Laboratoire de Physique et Chimie Quantique, Université M. Mammeri de Tizi-Ouzou, Hasnaoua, Algérie; Laboratoire de Physique des Gaz et des Plasmas, Univ. Paris-Sud, Orsay, France

**F. Bouvet** Synchrotron SOLEIL, Saint-Aubin, France

**C. Brown** Department of Electrical Engineering, Colorado State University and Engineering Research Center for Extreme Ultraviolet Science and Technology, Fort Collins, CO, USA

**P. Brůža** Czech Technical University, Prague, Czech Republic

**K. Buchanan** Physics Department, Colorado State University, Fort Collins, CO, USA

**S.V. Bulanov** Quantum Beam Science Directorate, JAEA, Kizugawa, Kyoto, Japan

**A.S. Busarov** P.N. Lebedev Physical Institute, Moscow, Russia

**A. Buteau** Synchrotron SOLEIL, Saint-Aubin, France

- A. Calisti** PIIM, CNRS-Aix-Marseille Université, Marseille, France
- S. Carbajo** NSF ERC for Extreme Ultraviolet Science and Technology, Department of Electrical & Computer Engineering, Colorado State University, Fort Collins, CO, USA
- B. Carré** CEA/DSM/IRAMIS/SPAM, Saclay, France
- L. Cassinari** Synchrotron SOLEIL, Saint-Aubin, France
- K. Cassou** CLUPS/LASERIX, Université Paris Sud XI, Orsay Cedex, France; LPGP, Univ. Paris-Sud, UMR 8578, CNRS, Orsay Cedex, France
- D. Castronovo** Elettra-Sincrotrone Trieste, Basovizza, Trieste, Italy
- N. Champion** Lerma, Observatoire de Paris, UPMC, CNRS, Paris, France
- W. Chao** NSF ERC for Extreme Ultraviolet Science and Technology, Department of Electrical & Computer Engineering, Colorado State University, Fort Collins, CO, USA; NSF ERC for Extreme Ultraviolet Science and Technology and Center for X-ray Optics, LBNL, Berkeley, CA, USA
- U. Chaulagain** Lerma, Observatoire de Paris, UPMC, CNRS, Paris, France
- K.T. Cheng** Lawrence Livermore National Laboratory, Livermore, CA, USA
- C. Constancias** CEA-LETI, Grenoble, France
- Manuel Cotelo** Instituto de Fusión Nuclear, Universidad Politécnica de Madrid, Madrid, Spain
- M.E. Couprie** Synchrotron SOLEIL, Saint-Aubin, France
- B. Cros** LPGP, Univ. Paris-Sud, UMR 8578, CNRS, Orsay Cedex, France
- M.A. Curtis** National Science Foundation ERC for Extreme Ultraviolet Science and Technology, Fort Collins, USA; Department of Electrical and Computer Engineering, Colorado State University, Fort Collins, CO, USA
- E. d’Humières** Univ. Bordeaux, CNRS, CEA, CELIA (Centre Lasers Intenses et Applications), Talence, France
- S. Daboussi** CLUPS/LASERIX, Université Paris Sud XI, Orsay Cedex, France; LPGP, Univ. Paris-Sud, UMR 8578, CNRS, Orsay Cedex, France
- H. Daido** Applied Laser Technology Institute Tsuruga Head Office, Japan Atomic Energy Agency, Tsuruga, Fukui, Japan; Quantum Beam Directorate, Japan Atomic Energy Agency, Kizugawa, Kyoto, Japan
- J. Daillant** Synchrotron SOLEIL, Saint-Aubin, France
- L.V. Dao** Centre for Atom Optics and Ultrafast Spectroscopy, Swinburne University of Technology, Melbourne, Australia; Australian Research Council Centre of Excellence for Coherent X-Ray Science, Melbourne, Australia



**Anderson Zanardi de Freitas** Centro de Lasers e Aplicações, IPEN, CNEN/SP, Sao Paulo, Brazil

**François de Gaufridy** Instituto de Fusión Nuclear, Universidad Politécnica de Madrid, Madrid, Spain; Institute of Physics, Czech Academy of Sciences, Prague, Czech Republic

**Paulo Sergio Fabris de Matos** Centro de Lasers e Aplicações, IPEN, CNEN/SP, Sao Paulo, Brazil

**G. De Ninno** Elettra-Sincrotrone Trieste, Basovizza, Trieste, Italy; Dept. of Physics, University of Nova Gorica, Nova Gorica, Slovenia

**O. Delmas** CLUPS/LASERIX, Université Paris Sud XI, Orsay Cedex, France; Amplitude Technologies, Lisses, France; LPGP, Univ. Paris-Sud, UMR 8578, CNRS, Orsay Cedex, France

**F. Delmotte** LCF, Institut d'Optique, CNRS, PXI, Palaiseau, France

**J. Demailly** CLUPS/LASERIX, Université Paris Sud XI, Orsay Cedex, France; Laboratoire de Physique des Gaz et Plasma, CNRS-Université Paris Sud, Orsay, France

**J.C. Denard** Synchrotron SOLEIL, Saint-Aubin, France

**G. Devanz** CEA/DSM/IRFU/SACM, Saclay, France

**Alberto G. de la Varga** Instituto de Fusión Nuclear, Universidad Politécnica de Madrid, Madrid, Spain

**S. Di Mitri** Elettra-Sincrotrone Trieste, Basovizza, Trieste, Italy

**K.B. Dinh** Centre for Atom Optics and Ultrafast Spectroscopy, Swinburne University of Technology, Melbourne, Australia; Australian Research Council Centre of Excellence for Coherent X-Ray Science, Melbourne, Australia

**J. Dostal** IoP/PALS Center, Prague, Czech Republic

**A. Dubois** LCPMR, Paris-VI, France

**Antonin Dusseix** Laboratoire de Physique des Gaz et Plasma, CNRS-Université Paris Sud, Orsay, France

**B. Ecker** Helmholtz Institute Jena, Jena, Germany; Johannes-Gutenberg Universität Mainz, Mainz, Germany

**U. Eisenbarth** GSI Helmholtz Center for Heavy-Ion Research, Darmstadt, Germany

**D. Elbaum** Institute of Physics, Polish Academy of Sciences, Warsaw, Poland

**T. Esirkepov** Quantum Beam Science Directorate, JAEA, Kizugawa, Kyoto, Japan

**C. Evain** PhLAM/CERLA, Lille, France

**P. Eymard** Synchrotron SOLEIL, Saint-Aubin, France

**A.Y. Faenov** Quantum Beam Science Directorate, JAEA, Kizugawa, Kyoto, Japan; Joint Institute for High Temperatures, Russian Academy of Science, Moscow, Russia

**M. Fajardo** Centro de Física dos Plasmas, Instituto Superior Técnico, Lisbon, Portugal

**Edilson Lucena Falcão** Physics Department, UFPE, Recife, Brazil

**Z.H. Fang** Shanghai Institute of Laser Plasma, Shanghai, China

**L. Farvacque** ESRF, Grenoble, France

**W. Fawley** Elettra-Sincrotrone Trieste, Basovizza, Trieste, Italy

**E. Ferrari** Elettra-Sincrotrone Trieste, Basovizza, Trieste, Italy; Dept. of Physics, University of Nova Gorica, Nova Gorica, Slovenia

**S. Ferri** PIIM, CNRS-Aix-Marseille Université, Marseille, France

**R.M. Feshchenko** P.N. Lebedev Physical Institute of RAS, Moscow, Russia

**Thomas Feurer** Institute of Applied Physics, University of Bern, Bern, Switzerland

**H. Fiedorowicz** Institute of Optoelectronics, Military University of Technology, Warsaw, Poland

**Vladimir Fortov** Joint Institute for High Temperatures, Russian Academy of Sciences, Moscow, Russia

**L. Froehlich** Elettra-Sincrotrone Trieste, Basovizza, Trieste, Italy

**Oleksandr Frolov** Pulse Plasma Systems Department, Institute of Plasma Physics AS CR, v.v.i., Prague, Czech Republic

**K. Fronc** Institute of Physics, Polish Academy of Sciences, Warsaw, Poland

**F. Furch** National Science Foundation ERC for Extreme Ultraviolet Science and Technology, Fort Collins, USA; Department of Physics, Colorado State University, Fort Collins, CO, USA

**N. Gaffney** Centre for Atom Optics and Ultrafast Spectroscopy, Swinburne University of Technology, Melbourne, Australia; Australian Research Council Centre of Excellence for Coherent X-Ray Science, Melbourne, Australia

**B. Gagey** Synchrotron SOLEIL, Saint-Aubin, France

**J. Gautier** Laboratoire d'Optique Appliquée, ENSTA, Palaiseau, France

**Aurelie Gense** Laboratoire de Physique des Gaz et Plasma, CNRS-Université Paris Sud, Orsay, France

- L. Giannessi** Elettra-Sincrotrone Trieste, Basovizza, Trieste, Italy; ENEA, Frascati, Italy
- S. Goette** GSI Helmholtz Center for Heavy-Ion Research, Darmstadt, Germany
- O. Guilbaud** CLUPS/LASERIX, Université Paris Sud XI, Orsay Cedex, France; LPGP, Univ. Paris-Sud, UMR 8578, CNRS, Orsay Cedex, France
- C.P. Hains** Department of Electrical Engineering, University of New Mexico and Center for High Technology Materials, Albuquerque, NM, USA
- C. Hall** Centre for Atom Optics and Ultrafast Spectroscopy, Swinburne University of Technology, Melbourne, Australia; Australian Research Council Centre of Excellence for Coherent X-Ray Science, Melbourne, Australia
- P. Hannaford** Centre for Atom Optics and Ultrafast Spectroscopy, Swinburne University of Technology, Melbourne, Australia; Australian Research Council Centre of Excellence for Coherent X-Ray Science, Melbourne, Australia
- N. Hasegawa** Quantum Beam Science Directorate, Japan Atomic Energy Agency, Kizugawa, Kyoto, Japan
- C. Herbeaux** Synchrotron SOLEIL, Saint-Aubin, France
- D.C. Hochhaus** ExtreMe Matter Institute EMMI, Darmstadt, Germany; Goethe-Universität Frankfurt, Frankfurt, Germany
- I.D. Howlett** NSF ERC for Extreme Ultraviolet Science and Technology, Department of Electrical & Computer Engineering, Colorado State University, Fort Collins, CO, USA
- T. Imazono** Quantum Beam Science Directorate, Japan Atomic Energy Agency, Kizugawa, Kyoto, Japan
- M. Ishino** Quantum Beam Science Directorate, Japan Atomic Energy Agency, Kizugawa, Kyoto, Japan
- A. Isoyan** Synopsys Inc., Hillsboro, OR, USA
- P. Jagourel** GEPI, Observatoire de Paris, Univ. Paris-Diderot, CNRS, Paris, France
- K.A. Janulewicz** Advanced Photonics Research Institute, Gwangju Institute of Science and Technology, Gwangju, Rep. of Korea
- R. Jarocki** Institute of Optoelectronics, Military University of Technology, Warsaw, Poland
- F. Jia** Institute of Applied Physics, University of Bern, Bern, Switzerland
- Q. Jin** Institute of Modern Physics, Chinese Academy of Sciences, Lanzhou, People's Republic of China
- Walter R. Johnson** University of Notre Dame, Notre Dame, IN, USA

**T. Kaihori** Quantum Beam Science Directorate, Japan Atomic Energy Agency, Kizugawa, Kyoto, Japan

**M. Kando** Quantum Beam Science Directorate, JAEA, Kizugawa, Kyoto, Japan

**Y. Kato** Quantum Beam Science Directorate, JAEA, Kizugawa, Kyoto, Japan

**T. Kawachi** Quantum Beam Science Directorate, Japan Atomic Energy Agency, Kizugawa, Kyoto, Japan

**S. Kazamias** CLUPS/LASERIX, Université Paris Sud XI, Orsay Cedex, France; LPGP, Univ. Paris-Sud, UMR 8578, CNRS, Orsay Cedex, France

**C.M. Kim** Advanced Photonics Research Institute, Gwangju Institute of Science and Technology, Gwangju, Rep. of Korea

**A. Klisnick** ISMO, CNRS-Université Paris-Sud, Orsay, France

**Karel Kolacek** Pulse Plasma Systems Department, Institute of Plasma Physics AS CR, v.v.i., Prague, Czech Republic

**K. Kondo** Quantum Beam Science Directorate, JAEA, Kizugawa, Kyoto, Japan

**J. Kostecki** Institute of Optoelectronics, Military University of Technology, Warsaw, Poland

**M. Kozlova** Institute of Physics of ASCR, Prague, Czech Republic; IoP/PALS Center, Prague, Czech Republic

**M. Krus** Institute of Physics of ASCR, Prague, Czech Republic; IoP/PALS Center, Prague, Czech Republic

**T. Kuehl** Helmholtz Institute Jena, Jena, Germany; GSI Helmholtz Center for Heavy-Ion Research, Darmstadt, Germany; ExtreMe Matter Institute EMMI, Darmstadt, Germany; Johannes-Gutenberg Universität Mainz, Mainz, Germany; GSI Helmholtzzentrum fuer Schwerionenforschung, Darmstadt, Germany

**M. Labat** Synchrotron SOLEIL, Saint-Aubin, France

**G. Lambert** Laboratoire d'Optique Appliquée, Palaiseau, France

**J. Larour** LPP, Ecole Polytechnique, UPMC, CNRS, Palaiseau, France

**T.T.T. Le** Laboratoire d'Optique Appliquée, Palaiseau cedex, France

**G. LeBec** ESRF, Grenoble, France

**R. Lefevre** Lerma, Observatoire de Paris, UPMC, CNRS, Paris, France

**R. Lehe** Laboratoire d'Optique Appliquée, Palaiseau, France

**A. Lestrade** Synchrotron SOLEIL, Saint-Aubin, France

**Haochuan Li** Institute of Precision Optical Engineering (IPOE), Physics Department, Tongji University, Shanghai, China

- L. Li** Laboratoire d'Optique Appliquée, Palaiseau cedex, France
- A. Lifschitz** Laboratoire d'Optique Appliquée, Palaiseau, France
- A. Louergue** Synchrotron SOLEIL, Saint-Aubin, France
- M. Luong** CEA/DSM/IRFU/SACM, Saclay, France
- B.M. Luther** National Science Foundation ERC for Extreme Ultraviolet Science and Technology, Fort Collins, USA; Department of Electrical and Computer Engineering, Colorado State University, Fort Collins, CO, USA
- J. Lüning** LCPMR, Paris-VI, France
- B. Mahieu** Elettra-Sincrotrone Trieste, Basovizza, Trieste, Italy; Dept. of Physics, University of Nova Gorica, Nova Gorica, Slovenia
- V. Malka** Laboratoire d'Optique Appliquée, Palaiseau, France
- E.B. Malm** Department of Electrical Engineering, Colorado State University and Engineering Research Center for Extreme Ultraviolet Science and Technology, Fort Collins, CO, USA
- P. Marchand** Synchrotron SOLEIL, Saint-Aubin, France
- M.C. Marconi** NSF Engineering Research Center for Extreme Ultraviolet Science & Technology and Department of Electrical and Computer Engineering, Colorado State University, Fort Collins, CO, USA
- J.L. Marlats** Synchrotron SOLEIL, Saint-Aubin, France
- D. Martz** National Science Foundation ERC for Extreme Ultraviolet Science and Technology, Fort Collins, USA; Department of Electrical and Computer Engineering, Colorado State University, Fort Collins, CO, USA
- Leili Masoudnia** Institute of Applied Physics, University of Bern, Bern, Switzerland
- G. Maynard** LPGP, Univ. Paris-Sud, UMR 8578, CNRS, Orsay Cedex, France
- E. Meltchakov** LCF, Institut d'Optique, CNRS, PXI, Palaiseau, France
- L.M. Meng** ISMO, CNRS-Université Paris-Sud, Orsay, France
- C.S. Menoni** NSF Engineering Research Center for Extreme Ultraviolet Science & Technology and Department of Electrical and Computer Engineering, Colorado State University, Fort Collins, CO, USA; National Science Foundation ERC for Extreme Ultraviolet Science and Technology, Fort Collins, USA
- R. Mercier** LCF, Institut d'Optique, CNRS, PXI, Palaiseau, France
- Y. Minami** Institute of Solid State Physics, The University of Tokyo, Kashiwa, Chiba, Japan
- C. Miron** Synchrotron SOLEIL, Saint-Aubin, France

**N.C. Monserud** Department of Electrical Engineering, Colorado State University and Engineering Research Center for Extreme Ultraviolet Science and Technology, Fort Collins, CO, USA

**P. Morin** Synchrotron SOLEIL, Saint-Aubin, France

**T. Morita** Quantum Beam Science Directorate, Japan Atomic Energy Agency, Kizugawa, Kyoto, Japan

**C. Mossé** PIIM, CNRS-Aix-Marseille Université, Marseille, France

**T. Muramatsu** Applied Laser Technology Institute Tsuruga Head Office, Japan Atomic Energy Agency, Tsuruga, Fukui, Japan

**A. Nadji** Synchrotron SOLEIL, Saint-Aubin, France

**T. Nakamura** Quantum Beam Science Directorate, JAEA, Kizugawa, Kyoto, Japan

**K. Namikawa** Research Institute for Science & Technology, Tokyo University of Science, Noda, Chiba, Japan

**J. NejdI** IoP/PALS Center, Prague, Czech Republic

**P. Neumayer** ExtreMe Matter Institute EMMI, Darmstadt, Germany

**O. Neveu** LPGP, Univ. Paris-Sud, UMR 8578, CNRS, Orsay Cedex, France; LASERIX, CLUPS, Univ. Paris-Sud, CNRS, Orsay Cedex, France

**Bich-Lien Nghiem** Laboratoire de Physique des Gaz et Plasma, CNRS-Université Paris Sud, Orsay, France

**P.V. Nickles** WCU Dept. of Nanobio Materials and Electronics, Gwangju Institute of Science and Technology, Gwangju, Rep. of Korea

**Joseph Nilsen** Lawrence Livermore National Laboratory, Livermore, CA, USA

**M. Nishikino** Quantum Beam Science Directorate, Japan Atomic Energy Agency, Kizugawa, Kyoto, Japan

**A. Nishimura** Applied Laser Technology Institute Tsuruga Head Office, Japan Atomic Energy Agency, Tsuruga, Fukui, Japan; Quantum Beam Directorate, Japan Atomic Energy Agency, Kizugawa, Kyoto, Japan

**G. Norman** Joint Institute for High Temperatures, Russian Academy of Sciences, Moscow, Russia; Moscow Institute of Physics and Technology, Moscow, Russia

**Y. Ochi** Quantum Beam Science Directorate, Japan Atomic Energy Agency, Kizugawa, Kyoto, Japan

**E. Oliva** Laboratoire d'Optique Appliquée, ENSTA ParisTech, École Polytechnique ParisTech, CNRS, UMR 7639, Palaiseau, France; Laboratoire d'Optique Appliquée, Palaiseau cedex, France

**D. Patel** National Science Foundation ERC for Extreme Ultraviolet Science and Technology, Fort Collins, USA; Department of Electrical and Computer Engineering, Colorado State University, Fort Collins, CO, USA

**D. Pánek** Czech Technical University, Prague, Czech Republic

**G. Penco** Elettra-Sincrotrone Trieste, Basovizza, Trieste, Italy

**T.A. Pikuz** Quantum Beam Science Directorate, JAEA, Kizugawa, Kyoto, Japan

**Tatiana Pikuz** Quantum Beam Science Directorate, Japan Atomic Energy Agency, Kyoto, Japan; Joint Institute for High Temperatures, Russian Academy of Sciences, Moscow, Russia

**A. Pirozhkov** Quantum Beam Science Directorate, JAEA, Kizugawa, Kyoto, Japan

**M. Pittman** LASERIX, CLUPS, Univ. Paris-Sud, CNRS, Orsay Cedex, France

**F. Polack** Synchrotron SOLEIL, Saint-Aubin, France

**A.V. Popov** Pushkov Institute of Terrestrial Magnetism, Ionosphere and Radiowave Propagation, Troitsk, Russia

**N.L. Popov** P.N. Lebedev Physical Institute, Moscow, Russia

**David Portillo** Instituto de Fusión Nuclear, Universidad Politécnica de Madrid, Madrid, Spain

**Chris Pouhe** Laboratoire de Physique des Gaz et Plasma, CNRS-Université Paris Sud, Orsay, France

**J. Prokupek** Institute of Physics of ASCR, Prague, Czech Republic; IoP/PALS Center, Prague, Czech Republic

**Vaclav Prukner** Pulse Plasma Systems Department, Institute of Plasma Physics AS CR, v.v.i., Prague, Czech Republic

**J.B. Pruvost** Synchrotron SOLEIL, Saint-Aubin, France

**X.M. Qiao** Institute of Applied Physics and Computational Mathematics, Beijing, China

**Rabia Qindeel** Centro de Lasers e Aplicações, IPEN, CNEN/SP, Sao Paulo, Brazil

**B.A. Reagan** National Science Foundation ERC for Extreme Ultraviolet Science and Technology, Fort Collins, USA; Department of Electrical and Computer Engineering, Colorado State University, Fort Collins, CO, USA

**F. Reix** GEPI, Observatoire de Paris, Univ. Paris-Diderot, CNRS, Paris, France

**F. Ribeiro** Synchrotron SOLEIL, Saint-Aubin, France

**J.P. Ricaud** Synchrotron SOLEIL, Saint-Aubin, France

**Gabriel Richet** Laboratoire de Physique des Gaz et Plasma, CNRS-Université Paris Sud, Orsay, France

**J.J. Rocca** NSF Engineering Research Center for Extreme Ultraviolet Science & Technology and Department of Electrical and Computer Engineering, Colorado State University, Fort Collins, CO, USA; National Science Foundation ERC for Extreme Ultraviolet Science and Technology, Fort Collins, USA; Department of Physics, Colorado State University, Fort Collins, CO, USA

**D. Ros** CLUPS/LASERIX, Université Paris Sud XI, Orsay Cedex, France; LPGP, Univ. Paris-Sud, UMR 8578, CNRS, Orsay Cedex, France

**A. Rousse** Laboratoire d'Optique Appliquée, Palaiseau, France

**R. Roux** Laboratoire de l'Accélérateur Linéaire, Orsay, France

**P. Roy** Synchrotron SOLEIL, Saint-Aubin, France

**Mabel Ruiz-Lopez** Institute of Applied Physics, University of Bern, Bern, Switzerland

**B. Rus** IoP/PALS Center, Prague, Czech Republic

**Ricardo Elgul Samad** Centro de Lasers e Aplicações, IPEN, CNEN/SP, Sao Paulo, Brazil

**A. Sasaki** Quantum Beam Science Directorate, Japan Atomic Energy Agency, Kizugawa, Kyoto, Japan

**Jiri Schmidt** Pulse Plasma Systems Department, Institute of Plasma Physics AS CR, v.v.i., Prague, Czech Republic

**S. Sebban** Laboratoire d'Optique Appliquée, ENSTA ParisTech, École Polytechnique ParisTech, CNRS, UMR 7639, Palaiseau, France

**V.N. Shlyaptsev** National Science Foundation ERC for Extreme Ultraviolet Science and Technology, Fort Collins, USA; Department of Electrical and Computer Engineering, Colorado State University, Fort Collins, CO, USA

**T. Shobu** Applied Laser Technology Institute Tsuruga Head Office, Japan Atomic Energy Agency, Tsuruga, Fukui, Japan; Quantum Beam Directorate, Japan Atomic Energy Agency, Kizugawa, Kyoto, Japan

**O.A. Shoutova** Physics Department, M.V. Lomonosov Moscow State University, Moscow, Russia

**Igor Skobelev** Joint Institute for High Temperatures, Russian Academy of Sciences, Moscow, Russia

**T.A. Smith** School of Chemistry, University of Melbourne, Melbourne, Australia; Australian Research Council Centre of Excellence for Coherent X-Ray Science, Melbourne, Australia

**C. Spezzani** Elettra-Sincrotrone Trieste, Basovizza, Trieste, Italy



**Sergei Starikov** Joint Institute for High Temperatures, Russian Academy of Sciences, Moscow, Russia; Moscow Institute of Physics and Technology, Moscow, Russia

**F. Staub** Institute of Applied Physics, University of Bern, Bern, Switzerland

**Vladimir Stegailov** Joint Institute for High Temperatures, Russian Academy of Sciences, Moscow, Russia; Moscow Institute of Physics and Technology, Moscow, Russia

**C. Stehlé** Lerma, Observatoire de Paris, UPMC, CNRS, Paris, France

**A. Stein** Center for Functional Nanomaterials, Brookhaven National Laboratory, Upton, NY, USA

**H. Stiel** Max-Born Institute for Nonlinear Optics and Short Pulse Spectroscopy, Berlin, Germany

**T. Stoehlker** Helmholtz Institute Jena, Jena, Germany; GSI Helmholtz Center for Heavy-Ion Research, Darmstadt, Germany

**Jaroslav Straus** Pulse Plasma Systems Department, Institute of Plasma Physics AS CR, v.v.i., Prague, Czech Republic

**S.Y. Stremoukhov** Physics Department, M.V. Lomonosov Moscow State University, Moscow, Russia

**T. Suemoto** Institute of Solid State Physics (ISSP), University of Tokyo, Kashiwa, Chiba, Japan

**K. Sugihara** Applied Laser Technology Institute Tsuruga Head Office, Japan Atomic Energy Agency, Tsuruga, Fukui, Japan

**J.R. Sun** Shanghai Institute of Laser Plasma, Shanghai, China

**F. Suzuki-Vidal** Imperial College, London, UK

**M. Szczurek** Institute of Optoelectronics, Military University of Technology, Warsaw, Poland

**C. Szwaj** PhLAM/CERLA, Lille, France

**K. Ta Phuoc** Laboratoire d'Optique Appliquée, Palaiseau, France

**B. Talin** PIIM, CNRS-Aix-Marseille Université, Marseille, France

**Greg Tallents** University of York, York, UK

**Satoshi Tamotsu** Division of Natural Science, Faculty, Nara Women's University, Nara, Japan

**M. Tanaka** Quantum Beam Science Directorate, Japan Atomic Energy Agency, Kyoto, Japan

**T. Tanikawa** Synchrotron SOLEIL, Saint-Aubin, France

**K. Terakawa** Institute of Solid State Physics, The University of Tokyo, Kashiwa, Chiba, Japan

**C. Thaury** Laboratoire d'Optique Appliquée, Palaiseau, France

**V.T. Tikhonchuk** Univ. Bordeaux, CNRS, CEA, CELIA (Centre Lasers Intenses et Applications), Talence, France

**F. Tissandier** LOA, Ecole Polytechnique, CNRS, Paris, France; Laboratoire d'Optique Appliquée, ENSTA, Palaiseau, France

**T. Tomita** Department of Ecosystem Engineering, The University of Tokushima, Tokushima, Japan; Faculty of Engineering, University of Tokushima, Tokushima, Japan

**M. Trovo** Elettra-Sincrotrone Trieste, Basovizza, Trieste, Italy

**L. Urbanski** NSF Engineering Research Center for Extreme Ultraviolet Science & Technology and Department of Electrical and Computer Engineering, Colorado State University, Fort Collins, CO, USA

**P. Velarde** Instituto de Fusión Nuclear, Universidad Politécnica de Madrid, Madrid, Spain

**Nilson Dias Vieira Junior** Centro de Lasers e Aplicações, IPEN, CNEN/SP, Sao Paulo, Brazil

**A.V. Vinogradov** P.N. Lebedev Physical Institute, Moscow, Russia

**Boris Vodungbo** Laboratoire d'Optique Appliquée, ENSTA ParisTech – CNRS – École Polytechnique, Palaiseau, France

**H.L. Vu** Centre for Atom Optics and Ultrafast Spectroscopy, Swinburne University of Technology, Melbourne, Australia; Australian Research Council Centre of Excellence for Coherent X-Ray Science, Melbourne, Australia

**P.W. Wachulak** Institute of Optoelectronics, Military University of Technology, Warsaw, Poland

**C. Wang** Shanghai Institute of Laser Plasma, Shanghai, China

**S. Wang** National Science Foundation ERC for Extreme Ultraviolet Science and Technology, Fort Collins, USA; Department of Electrical and Computer Engineering, Colorado State University, Fort Collins, CO, USA

**S.J. Wang** Shanghai Institute of Laser Plasma, Shanghai, China

**W. Wang** Shanghai Institute of Laser Plasma, Shanghai, China

**Y. Wang** National Science Foundation ERC for Extreme Ultraviolet Science and Technology, Fort Collins, USA; Department of Electrical and Computer Engineering, Colorado State University, Fort Collins, CO, USA

**Zhanshan Wang** Institute of Precision Optical Engineering (IPOE), Physics Department, Tongji University, Shanghai, China

**K. Wernsing** National Science Foundation ERC for Extreme Ultraviolet Science and Technology, Fort Collins, USA; Department of Electrical and Computer Engineering, Colorado State University, Fort Collins, CO, USA

**Ł. Węgrzyński** Institute of Optoelectronics, Military University of Technology, Warsaw, Poland

**Lucy Wilson** University of York, York, UK

**D. Winters** GSI Helmholtz Center for Heavy-Ion Research, Darmstadt, Germany

**M. Woolston** National Science Foundation ERC for Extreme Ultraviolet Science and Technology, Fort Collins, USA; Department of Electrical and Computer Engineering, Colorado State University, Fort Collins, CO, USA

**H. Xu** Department of Electrical Engineering, University of New Mexico and Center for High Technology Materials, Albuquerque, NM, USA

**T. Yamada** Applied Laser Technology Institute Tsuruga Head Office, Japan Atomic Energy Agency, Tsuruga, Fukui, Japan

**M. Yamagiwa** Quantum Beam Science Directorate, Japan Atomic Energy Agency, Kizugawa, Kyoto, Japan

**M. Yamamoto** Department of Ecosystem Engineering, The University of Tokushima, Tokushima, Japan

**S. Yamashita** Applied Laser Technology Institute Tsuruga Head Office, Japan Atomic Energy Agency, Tsuruga, Fukui, Japan

**L. Yin** National Science Foundation ERC for Extreme Ultraviolet Science and Technology, Fort Collins, USA; Department of Electrical and Computer Engineering, Colorado State University, Fort Collins, CO, USA

**P. Zeitoun** Laboratoire d'Optique Appliquée, ENSTA ParisTech, École Polytechnique ParisTech, CNRS, UMR 7639, Palaiseau, France

**H. Zhao** Institute of Modern Physics, Chinese Academy of Sciences, Lanzhou, People's Republic of China

**W.D. Zheng** Institute of Applied Physics and Computational Mathematics, Beijing, China

**Jingtao Zhu** Institute of Precision Optical Engineering (IPOE), Physics Department, Tongji University, Shanghai, China

**B. Zielbauer** GSI Helmholtz Center for Heavy-Ion Research, Darmstadt, Germany; Helmholtz Institute Jena, Jena, Germany; GSI Helmholtzzentrum fuer Schwerionenforschung, Darmstadt, Germany

# Chapter 1

## Coherent Pulses from a Seeded Free-Electron Laser in the Extreme Ultraviolet

E. Allaria, D. Castronovo, G. De Ninno, S. Di Mitri, W. Fawley, E. Ferrari, L. Froehlich, L. Giannessi, B. Mahieu, G. Penco, C. Spezzani, and M. Trovo

**Abstract** We report results of a free-electron laser operating with the high gain harmonic generation configuration in the wavelength range from 60 to 20 nm. With the recent experiments done at the FERMI free-electron laser facility in Trieste we demonstrated the capability of the used method to produce highly coherent pulses allowing to improve the performances of FELs in the EUV spectral range overcoming some of the limitations that are typical of systems based on the self amplified spontaneous emission (SASE). Taking advantage of the seeding scheme adopted for FERMI high photon energy stability and a very high longitudinal and transverse coherence have been measured. The operation of the FERMI FEL facility will allow improving the use of the FEL light for those experiments that require a small spectral bandwidth or a precise control of the photon energy.

### 1 Introduction

FERMI@Elettra is a fourth generation light source under commissioning that has been built at the Elettra laboratory in Trieste. When in operation FERMI@Elettra will allow the Elettra user community to perform new kinds of experiments that could exploit the characteristic of such a new light source like short pulses and high peak intensity.

Free electron lasers have been recognized since the first proposal [1] and demonstration [2, 3] as possible sources that could be efficiently used for the generation of laser like pulses in the x-ray spectral range. Although it has been necessary to

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E. Allaria (✉) · D. Castronovo · G. De Ninno · S. Di Mitri · W. Fawley · E. Ferrari · L. Froehlich · L. Giannessi · B. Mahieu · G. Penco · C. Spezzani · M. Trovo  
Elettra-Sincrotrone Trieste, S.S. 14—km 163.5 in Area Science Park, 34012 Basovizza, Trieste, Italy  
e-mail: [enrico.allaria@elettra.trieste.it](mailto:enrico.allaria@elettra.trieste.it)

G. De Ninno · E. Ferrari · B. Mahieu  
Dept. of Physics, University of Nova Gorica, Nova Gorica, Slovenia

L. Giannessi  
ENEA, Frascati, Italy

wait for the technology to be mature in order to support the requirements for x-rays FELs, the theory of high gain single pass FELs was developed [4, 5] showing how the self amplified spontaneous emission (SASE) FELs could be designed to operate in the x-ray spectral range. Since the first theoretical works, several projects have been done for demonstrating and use such a capability.

After first experiments in the infrared [6] and in the visible [7] the wavelength range has been rapidly extended from the VUV [8] up to the soft x-ray [9]. More recently the final goal to reach the hard x-ray spectral range has been achieved showing FEL operations at 1.5 and 1.2 Ångstrom [10, 11].

The recent progress on short wavelength FELs has been accompanied by the progress of other sources of laser-like pulses in the VUV and soft x-ray spectral range. Several methods have been proposed and studied for the generation of x-ray laser-like pulses that use the nonlinear response of materials to very high power laser pulses in the visible and near infrared [12–16].

In this work we will report about the recent results achieved at FERMI@Elettra with the first seeded FEL operated in the range between 65 and 20 nm.

## 2 The FERMI@Elettra Free Electron Laser

The FERMI FELs will produce photons in the ultraviolet and soft x-ray range, between 80 and 4 nm (Fig. 1).

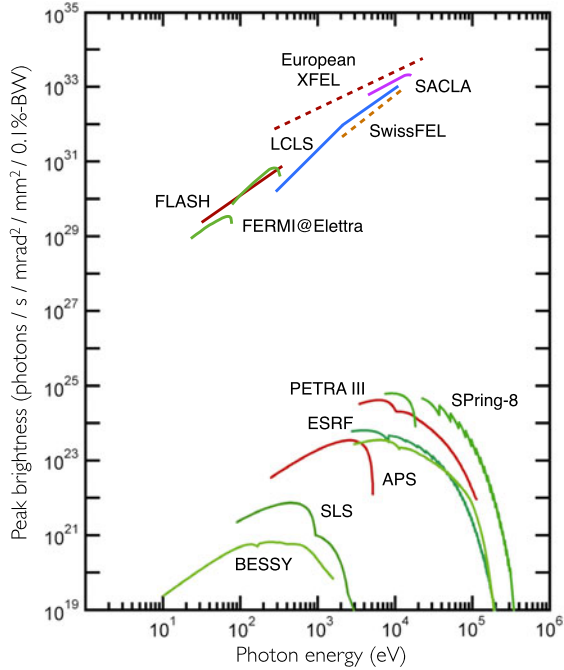
Three experimental programs define the scientific case and have driven the design of the facility. The three FERMI experimental beamlines, Diffraction and Projection Imaging (DiProI), Elastic and Inelastic Scattering (EIS), Low Density Matter (LDM), require for their experiments high peak brightness, fully coherent, narrow and stable bandwidth photon pulses. Wavelength tunability and variable polarization, circular and linear, are also required [17, 18].

In order to cover the large spectral range FERMI has been designed with two FEL lines. FEL-1, based on a High Gain Harmonic Generation (HG) [19] single stage, is seeded by an external UV laser at about 260 nm [20]. FEL-1 produces photons in the wavelength range between 80 and 20 nm (15 eV to 62 eV). To reach 4 nm wavelength (310 eV), starting from an external seed laser in the UV range, a double stage HG cascade has been adopted for FEL-2.

Both FELs use the high energy and brightness electron bunches produced by a linear accelerator (Fig. 2). The accelerator is based on a normal conducting LINAC working at 3 GHz RF frequency and 50 Hz repetition rate. The high brightness electron beam is generated by a photocathode RF gun. Two stages of magnetic compression are used to get extremely short electron bunches (less than 1 ps) with high peak current.

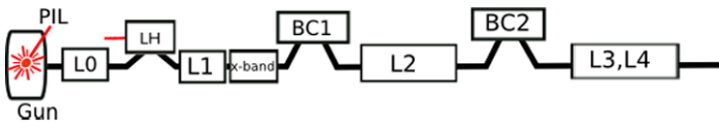
A fourth harmonic RF structure (12 GHz, X-band) provides the longitudinal phase space linearization needed to optimize the compression process. At high compression factors, i.e. high peak bunch currents, micro-bunching instabilities are predicted; to cure them, a laser heater [21] is installed at 100 MeV to increase in a controlled way the incoherent energy spread of the electron beam.

**Fig. 1** Diagram showing the expected performance of FERMI in terms of peak brilliance as compared to other FEL and synchrotron radiation facilities (Image from: P. Schmüser, M. Dohlus, J. Rossbach, and C. Behrens, Free-Electron Lasers in the Ultraviolet and X-Ray Regime: Physical Principles, Experimental Results, Technological Realization, 2nd edition to be printed in Springer-Verlag, Berlin (2013))



Each stage of the two FEL lines is made up by the modulator, where the electron beam is seeded by the external laser, a dispersive bunching section, and the radiator, where the interaction between the electron beam and the produced coherent radiation produces the exponential growth of the FEL radiation. In Fig. 3 we show the schematic layout of the first FEL, FEL-1, that is based on a single stage harmonic generation.

For both FEL-1 and FEL-2 the final radiator is made up by six APPLE-II undulators, with magnetic periods of 55 and 35 mm respectively. APPLE-II undulators provide full control of the polarization of the FEL radiation and the variable gap allows changing the wavelength of the emitted radiation.



**Fig. 2** Schematic layout of the FERMI linear accelerator. Electron bunches are produced in the Gun by 5 ps pulses from a Photo-Injector Laser (PIL). A first acceleration structure (L0) is used to accelerate the beam up to 100 MeV, where there is the laser heater (LH). Further acceleration is produced by L1, and an x-band cavity is used to linearize the phase space before the first bunch compressor (BC1). Further acceleration is produced by L2 and L3, L4 and if needed additional compression can be achieved using the second bunch compressor chicane (BC2)